

Substitute Form PTO-1449 (Modified) MAR 19 2004 (37 CFR 1.98(b)) PATENT & TRADEMARK OFFICE	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 14414-017001	Application No. 10/761,742
	Information Disclosure Statement by Applicant (Use several sheets if necessary)		
	Applicant Raluca Dinu et al.		Filing Date January 21, 2004 Group Art Unit 2879

U.S. Patent Documents

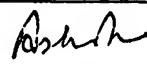
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA	5,120,339	06/09/92	Markovich et al.			
ab	AB	5,198,513	03/30/93	Clement et al.			
ab	AC	5,219,788	06/15/93	Abernathey et al.			
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Examiner Signature <i>Ashu</i>	Date Considered 3/16/06
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

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U.S. Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
af	ACC	6,466,707	10/15/02	Dawes, et al.			
af	ADD	6,473,551	10/29/02	Norwood, et al.			
	AEE	10/264,461	N/A	Dinu et al.			
	AFF	10/301,978	N/A	Huang et al.			

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
af	AGG	961139	01/12/99	EP			X	
af	AHH	10049443	02/20/98	JP			X	
af	AII	2001255426	09/21/01	JP			X	
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af	AKK	10232323	09/02/98	JP			X	
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Other Documents (include Author, Title, Date, and Place of Publication)		
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af	AMM	Bailey et al., "Step and flash imprint lithography: Template surface treatment and defect analysis," <i>J. Vac. Sci. Technol. B</i> , 2000, 18(6):3572-3577
af	ANN	Chen et al., "Thermosetting Polyurethanes with Stable and Large Second-Order Optical Nonlinearity," <i>Macromolecules</i> , 1992, 25:4032-4035
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af	ATT	Resnick et al., "Release Layers for Contact and Imprint Lithography," <i>Semicon. Int.</i> , June 2002, online version, 7 pgs.

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